Notice of Allowability	Application No.	Applicant(s)	Applicant(s)	
	09/767,722	MARTIN ET AL.		
	Examiner	Art Unit	T	
	Naghmeh Mehrpour	2617		
The MAILING DATE of this communication appeals all claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed); a Notice of Allowance (PTOL-85 NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT R of the Office or upon petition by the applicant. See 37 CFR 1.313	(OR REMAINS) CLOSED in th ) or other appropriate communic IGHTS. This application is subj	is application. If not inclu cation will be mailed in du	ded e course. <b>THIS</b>	
1. This communication is responsive to <u>9/5/06</u> .				
2. ☑ The allowed claim(s) is/are <u>2-5,7,9 and 10</u> .				
<ol> <li>Acknowledgment is made of a claim for foreign priority unally all blacks and blacks are all blacks.</li> <li>All blacks are all blacks are all blacks are all blacks.</li> <li>Certified copies of the priority documents have a copies of the certified copies of the priority documents have a copies of the certified copies of the priority documents have a copies of the certified copies of the priority documents have a copies of the certified copies of the certified copies are certified copies are certified copies.</li> </ol>	e been received. e been received in Application N	No	cation from the	
Applicant has THREE MONTHS FROM THE "MAILING DATE" noted below. Failure to timely comply will result in ABANDONN THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.	of this communication to file a I MENT of this application.	reply complying with the r	equirements	
4. A SUBSTITUTE OATH OR DECLARATION must be subm INFORMAL PATENT APPLICATION (PTO-152) which giv			NOTICE OF	
5. ☐ CORRECTED DRAWINGS ( as "replacement sheets") must (a) ☐ including changes required by the Notice of Draftspers 1) ☐ hereto or 2) ☐ to Paper No./Mail Date  (b) ☐ including changes required by the attached Examiner' Paper No./Mail Date  Identifying indicia such as the application number (see 37 CFR 1 each sheet. Replacement sheet(s) should be labeled as such in 6. ☐ DEPOSIT OF and/or INFORMATION about the deposit	son's Patent Drawing Review ( 's Amendment / Comment or in 1.84(c)) should be written on the c the header according to 37 CFR 1	the Office action of drawings in the front (not the continuation).	•	
attached Examiner's comment regarding REQUIREMENT	FOR THE DEPOSIT OF BIOLO	DGICAL MATERIAL.	Note the	
Attachment(s)  1. ☐ Notice of References Cited (PTO-892)  2. ☐ Notice of Draftperson's Patent Drawing Review (PTO-948)  3. ☐ Information Disclosure Statements (PTO/SB/08), Paper No./Mail Date  4. ☐ Examiner's Comment Regarding Requirement for Deposit of Biological Material	6. ☐ Interview Sum Paper No./Ma 7. ☐ Examiner's Ap	il Date	•	

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## **EXAMINER'S AMENDMENT**

1. An examiner's amendment to the record appears below. Should the changes and/or additions be unacceptable to applicant, an amendment may be filed as provided by 37 CFR 1.312. To ensure consideration of such an amendment, it MUST be submitted no later than the payment of the issue fee.

The application has been amended as follows:

In claim 10, the status identifier should be changed from "previously presented" amended to "currently presented", please make the above correction.

#### Reason for allowance

## Allowable Subject Matter

- 2. Claims 2-5, 7, 9-10, are allowed.
- 3. The following is an examiner's statement of reasons for allowance:

Regarding **claims 7, 9-10,** the present application teaches a crystal for a watch including a keyboard the crystal comprising a central portion of constant thickness and beveled peripheral portion. The beveled peripheral portion, considered as the thinned portion by that has a variable thickness which decreases towards the outside as specifically mentioned on claims 7, 9-10.

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The closet prior art such as Hatuse (US Patent 4,257,115) teaches a crystal for a watch including a keyboard the crystal comprising a central portion of constant thickness and beveled peripheral portion. Hatuse teaches the surface of each of the keys of the keyboard spreads over both the central thick portion and also the beveled portion of the crystal. Hatuse does not offer a reliable control especially with a crystal having a thickness sufficiently thick to be water resistant, as the capacitance will vary depending on the location where the user places his finger on the external portion, on the beveled portion or even between the central and the beveled portions of the crystal.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

### Conclusion

# 4. Any responses to this action should be mailed to:

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Naghmeh Mehrpour whose telephone number is 571-272-7913. The examiner can normally be reached on 8:00-6:00.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Marsha Banks-Harold be reached (571) 272-7905.

The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

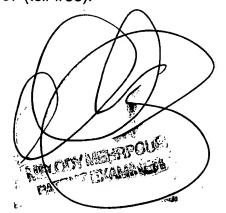
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NM

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Reaso4n for allowance

Allowable Subject Matter

1. Claims 2-5, 7, 9-10, are allowed.

2. The following is an examiner's statement of reasons for allowance:

Regarding **claims 7, 9-10,** the present application teaches a crystal for a watch including a keyboard the crystal comprising a central portion of constant thickness and beveled peripheral portion. The beveled peripheral portion, considered as the thinned portion by that has a variable thickness which decreases towards the outside as specifically mentioned on claims 7, 9-10.

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